KINETICS OF GRAPHENE OXIDE THERMAL DECOMPOSITION IN THE PRESENCE OF CARBON SUBOXIDE

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INTRODUCTION

Graphene is an allotrope of carbon that possesses unique thermal, chemical, electrical, optical, physical, and mechanical properties. It has broad application prospects in high-frequency electronics, water purification systems, semiconductor materials, drug carriers, flexible energy storage, and biosensing devices [1]. Nowadays, thermal reduction of graphene oxide (GO) is one of the potential synthesis methods to obtain graphene in a simple, low-cost, high yield, and time-saving way. However, GO is attributed to a class of energetic materials due to its high enthalpy change of thermal decomposition (ΔH). Thus, it could decompose violently if not properly stored and handled, and cause irreversible damage [2]. Furthermore, the mechanism of thermal reduction of GO is complex and not yet fully understood because of the consecutive stages of water evaporation, oxygen-containing functional groups removal, and basalplane carbon decomposition occurring during the thermal exfoliation [3]. Therefore, it is necessary to focus on the kinetic analysis of GO thermal decomposition for a deeper understanding of the behaviour of the exothermic reduction reaction and ensuring safe manufacturing of graphene.

<u>The aim of this study</u> was to analyse the impact of carbon suboxide (C_3O_2) on



KINETIC ANALYSIS



Table 1. Parameters of DSC peaks and determined values of decomposition enthalpy at the heating rates of 2.5, 5, and 10 °C min⁻¹.

	<i>6</i> (°C min⁻¹)	T _{onset} (°C)	<i>т_m</i> (°С)	<i>ΔΗ</i> (J g ^{−1})
	2.5	166	190	1449.52
GO	5	173	201	1477.89
	10	186	207	1534.12
	2.5	125	149	1083.47
GO_MA_P	5	133	158	1169.65
	10	140	167	1296.88

Kinetic models



Table 2. Determined values of activation energy for GO and GO_MA_P by different kinetic models.

Borchardt-Daniels			Ozawa		Kissinger	
в	E _a	D ²	Ea	D ²	E _a	D ²
(°C min⁻¹)	(kJ mol ^{−1})	K-	(kJ mol ^{−1})	K-	(kJ mol ^{−1})	R-



(mW)

flow

• 10 °C min⁻¹

	2.5	134.9	0.9980					
GO	5	137.8	0.9941	142.1	0.9713	141.5	0.9682	
	10	143.1	0.9931					
	2.5	107.5	0.9991					
GO_MA_P	5	110.7	0.9948	115.2	0.9999	114.0	0.9999	
	10	115.8	0.9990					

Fig. 2. DCS curves of (a) GO and (b) GO_MA_P at heating rates of 2.5, 5, and 10 °C min⁻¹.

CONCLUSION

() -20 M −20 M −10 • 10 °C min⁻¹

DSC results revealed that the reduction temperature of GO is reduced (up to 125 °C) by using C_3O_2 . Moreover, it was observed that C_3O_2 lowers the enthalpy ΔH and activation energy E_a but does not influence the reaction order *n* of GO thermal decomposition. The values of E_a for the thermal deposition of GO and GO_MA_P were obtained similar by using all three methods (Kissinger, Ozawa and Borchardt-Daniels). Results obtained by Borchardt-Daniels method showed that the values of E_a increase with increasing the heating rate for both studied samples. The apparent reaction order *n* for both GO and GO_MA_P equals 0.7. In fact, the mechanism of this process can be modelled including simultaneous zero-order and first-order stages. The zero-order process may originate in the case when the energy consumed in the thermal decomposition reaction comes through the basal graphene plane; then the reaction rate should not depend on the reagent concentration (i.e., the concentration of functional groups). The first-order process may occur in the case when the energy is absorbed directly by a functional group; this time the reaction rate depends only on the concentration of the reagent. The same reaction order for GO and GO_MA_P reduction reveals the same mechanism for both processes.

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